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| INFORMATION DISCLOSURE CITATION <i>(Use several sheets if necessary)</i> | | | | Docket Number (Optional) | | Application Number | |
| | | | | 44802-0193 | | 10/532,845 | |
| | | | | Applicant(s) | | | |
| | | | | Jiuhuai Lu et al. | | | |
| | | | | Filing Date | | Group Art Unit | |
| | | | | April 27, 2005 | | 2621 | |

| U. S. PATENT DOCUMENTS | | | | | | | |
|------------------------|-----|-----------------|------|------|-------|----------|----------------------------|
| EXAMINER INITIAL | REF | DOCUMENT NUMBER | DATE | NAME | CLASS | SUBCLASS | FILING DATE IF APPROPRIATE |
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| U.S. PATENT APPLICATION PUBLICATIONS | | | | | | | |
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| EXAMINER INITIAL | REF | DOCUMENT NUMBER | DATE | NAME | CLASS | SUBCLASS | FILING DATE IF APPROPRIATE |
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| FOREIGN PATENT DOCUMENTS | | | | | | | | |
|--------------------------|-----|-----------------|-----------|-------------------------------------|-------|----------|-------------|----|
| EXAMINER INITIAL | REF | DOCUMENT NUMBER | DATE | COUNTRY | CLASS | SUBCLASS | Translation | |
| | | | | | | | YES | NO |
| | | 63-199589 | 8.18.1988 | Japan w/Partial English translation | | | X | |
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| OTHER DOCUMENTS <i>(Including Author, Title, Date, Pertinent Pages, Etc.)</i> | | |
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| EXAMINER INITIAL | REF | |
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| EXAMINER /Y Lee/ | DATE CONSIDERED 03/04/2009 |
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EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.